

Transaction Information

Tool ID	STP1420
Tool Status	Running Wafers
Location	
Wafer Size	300 mm
Fab Section	Lithography
Tool Available Date	2024-02-25

General Product Information

Vendor Supplier	NIKON
Model	NSR-S208D
Vintage	2011
Asset Description	Lithography Step and repeat scanning system
Software Version	1.80 MCSW+OCSW
CIM	SECS
Process	Exposure Wafers (248nm) KRF

Hardware Configuration (Fab)

System Type	Description	Quantity	Status
Main System	NA		OK
Factory Interface	FOUP	1	OK
Options System			

Hardware Configuration (Subfab / Auxilliary Units)

Description	Quantity	Status
right site operation unit	1	OK

Missing/Faulty Parts / Accesories List

Description	Quantity
NA	